

This listing of claims will replace all prior versions, and listings, of claims in the application:

**Listing of Claims:**

Claims 1-44. (canceled)

45. (currently amended) A laser comprising:

a laser-resonator including an output coupling mirror, said resonator having an optical length of at least five centimeters;

an OPS-structure having a surface-emitting gain-structure, said gain-structure including a plurality of active layers having separator layers therebetween said active layers having a composition selected to provide emission of electromagnetic radiation at a fundamental wavelength within a gain bandwidth of said gain-structure, when optical-pump light is incident on said gain-structure;

said OPS structure being supported on a substrate located outside said laser-resonator with said gain-structure of said OPS-structure being inside said laser resonator;

a heat-sink arrangement for cooling said OPS-structure; and

an optical arrangement for delivering said pump-light to said gain-structure having a spot size of at least 200 microns at the gain structure, thereby causing fundamental laser-radiation having said fundamental-wavelength to oscillate in said laser-resonator; and

an optically-nonlinear crystal located in said laser-resonator and arranged for frequency-doubling said fundamental laser-radiation thereby providing frequency-doubled radiation having a wavelength half of said fundamental-wavelength, with the frequency-doubled radiation exiting the cavity through the output coupling mirror is greater than about 100mw.

46. (previously presented) The laser of claim 45, wherein said pump light is directed to said gain structure at a non-normal angle of incidence.

47. (previously presented) The laser of claim 45, wherein said output coupler is has a concave surface.

48. (previously presented) The laser of claim 45, wherein the radiation exiting the cavity has a mode quality of better than 2.0.

49. (previously presented) The laser of claim 45, wherein the radiation exiting the cavity has a mode quality of about 1.2.

50. (previously presented) The laser of claim 45, further including a wavelength selective element in the resonator.

51. (previously presented) The laser of claim 50, wherein said wavelength selective element is a birefringent filter.

52. (previously presented) The laser of claim 45, wherein said OPS structure includes a mirror structure surmounted by said gain-structure and said mirror structure is said first mirror.

Claims 53-58. (cancelled)

59. (currently amended) A laser, comprising:

a laser resonator formed by at least two mirrors, said resonator having an optical length of at least five centimeters;

an OPS-structure having a surface-emitting gain-structure, said gain-structure including a plurality of active layers having separator layers therebetween said active layers having a composition selected to provide emission of electromagnetic radiation at a predetermined fundamental-wavelength when optical-pump light is incident on said gain-structure;

said laser-resonator configured to include said gain-structure of said OPS-structure;

an optical arrangement for delivering said pump-light to a substantially single region having a spot size of at least 200 microns on said gain-structure, thereby causing fundamental laser-radiation having said fundamental-wavelength to circulate in said laser-resonator;

a heat-sink arrangement for cooling said OPS-structure; and

said laser-resonator, said OPS-structure, said heat-sink arrangement and said optical pump-light-delivering arrangement selected and arranged such that said resonator delivers output-radiation having said fundamental-wavelength at a power greater than 2 W.

60. (previously presented) The laser of claim 59, wherein said resonator is formed by three mirrors.

Claims 61- 69. (cancelled)

70. (currently amended) A method of selectively irradiating a material having a characteristic absorption band in a spectral region between about 425 and 1800 nm, the irradiation being for one or more of cutting, ablating, heating or photochemically altering the material, the method comprising the steps of:

- (a) providing an OPS-laser, said OPS-laser including an OPS-structure having a gain-structure incorporated into a laser resonator said resonator having an optical length of at least five centimeters, said gain structure including a plurality of active layers having separator layers therebetween, said active layers having a composition selected to provide generation by said laser resonator of fundamental laser-radiation having a wavelength which is within the characteristic absorption band of the material when optical-pump light is delivered to substantially a single region having a spot size of at least 200 microns on said gain-structure;
- (b) coupling fundamental radiation out of said OPS laser as output-radiation having a power greater than 2 Watts; and
- (c) delivering said output-radiation to the material.

71. (previously presented) The method of claim 70, wherein said output radiation is delivered via at least one of a lightguide, an articulated arm, and an optical-focusing system.

72. (previously presented) The method of claim 70, wherein said output-radiation coupled out of the laser is a single axial-mode.

73. (currently amended) A laser, comprising:

an OPS-structure having a gain-structure surmounting a mirror-structure, said gain-structure including a plurality of active layers having pump-light-absorbing layers therebetween, said active layers having a composition selected to provide emission of electromagnetic radiation at a predetermined fundamental-wavelength between about 425 nanometers and 1800 nanometers when optical-pump light is incident on said gain-structure;

a laser-resonator formed between said mirror-structure of said OPS-structure and a reflector spaced apart therefrom, said resonator having an optical length of at least five centimeters;

an optical arrangement for delivering said pump-light to said gain-structure having a spot size of at least 200 microns at the gain structure, thereby causing fundamental laser-radiation having said fundamental-wavelength to oscillate in said laser-resonator;

an optically-nonlinear crystal located in said laser-resonator and arranged for frequency-doubling said fundamental laser-radiation thereby providing frequency-doubled radiation having a wavelength half of said fundamental-wavelength; and

said laser-resonator, said optically nonlinear-crystal, said OPS-structure, and said optical pump-light-delivering arrangement selected and arranged such that said resonator delivers said frequency-doubled radiation as output-radiation in a plurality of transverse modes, said output radiation having a wavelength between about 212 nanometers and 900 nanometers at an output-power greater than about 100 milliwatts.

74. (previously presented) The laser of claim 73, wherein said output-power is greater than 5 Watts.

Claims 75-86. (cancelled)

87. (previously presented) The laser of claim 45, wherein the frequency doubled radiation exiting the cavity is greater than 1 Watt.

88. (previously presented) The laser of claim 45, wherein the frequency doubled radiation exiting the cavity is greater than 5 Watts.

89. (previously presented) The laser of claim 73, wherein said output-power is greater than 1 Watt.

90. (new) The laser of claim 45, wherein the resonator has an optical length of at least ten centimeters.

91. (new) The laser of claim 59, wherein the resonator has an optical length of at least ten centimeters.

92. (new) The method of claim 70, wherein the resonator has an optical length of at least ten centimeters.

93. (new) The laser of claim 73, wherein the resonator has an optical length of at least ten centimeters.

94. (new) The laser of claim 45, wherein the spot size of the pump-light at the gain structure has a  $1/e^2$  radius of about 230 micrometers.

95. (new) The laser of claim 59, wherein the spot size of the pump-light at the gain structure has a  $1/e^2$  radius of about 230 micrometers.

96. (new) The method of claim 70, wherein the spot size of the pump-light at the gain structure has a  $1/e^2$  radius of about 230 micrometers.

97. (new) The laser of claim 73, wherein the spot size of the pump-light at the gain structure has a  $1/e^2$  radius of about 230 micrometers.

98. (new) The laser of claim 45, wherein said heat sink arrangement includes a metal base and a layer of diamond between the metal base and the OPS structure.

99. (new) The laser of claim 59, wherein said heat sink arrangement includes a metal base and a layer of diamond between the metal base and the OPS structure.

100. (new) The laser of claim 73, further including a heat sink arrangement for cooling the OPS structure, said heat sink arrangement including a metal base and a layer of diamond between the metal base and the OPS structure.